Precision Measurement of Electrical Characteristics of Quartz-Crystal Units*

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Summary-Extensive manufacture and use of quartz-crystal units for radio communication, instrumentation, control, and detection purposes was responsible for new investigations to improve all phases of piezoelectric units and devices. A small part of the total work included development of circuit arrangements and instruments for accurately measuring the electrical constants of crystal units. This paper describes precision methods of high-frequency radio measurements as used successfully on quartz-crystal units and applicable to other types of units having Q's and impedance ranges up to several million or higher.

I. INTRODUCTION

S A RESULT of the enormous demand for quartz-crystal units in the recent war, many new methods of production, measurement, and testing were studied and put to use. Precise measurements of many characteristics of crystal units were made, but data concerning the dynamic electric impedance were supplied largely in an arbitrary and indirect manner.1,2

The electrical characteristics of a crystal unit, i.e., the impedance, the equivalent reactance, and the equivalent resistance at any point of operation may be measured and specified entirely apart from any external circuit with which the crystal unit is used.³⁻⁵ From these data the behavior of a crystal unit in any specific external circuit whose characteristics are known may be predicted. Although the great advantages of using this kind of data as the basis for a standardization of crystal units are described at length by others,^{3,5} it may briefly be noted that this application would eliminate the multitude of comparison test sets and the associated problems of calibration and maintenance required by today's indirect methods of specification, and should lead to more exact methods of measurement and performance rating in terms of those parameters likely to be most useful to the radio and electronics design engineer.

This paper reviews means of expressing the equivalent electrical circuit of a quartz-crystal unit. It describes measurement methods and techniques in which a generator of continuously adjustable frequency of stability comparable to that of a crystal unit permits the use of such laboratory instruments as rf bridges and Q meters to determine the crystal unit's electrical parameters. It shows how the techniques may be used for exploring secondary responses in a crystal unit to determine its usefulness as an element in filter circuits and to investigate causes of instability in oscillator circuits. The data are presented in simple graphical form favoring differentiation between a "normal" crystal unit and one remaining constant under limited conditions. Finally, correlation is shown between data based on the more fundamental crystal-unit characteristics and data derived from the more familiar "activity" and "stability" of a particular oscillator.

This work was done in connection with development of precision laboratory methods of measuring high-O components.

II. EQUIVALENT CIRCUIT REPRESENTING A NORMAL MODE OF VIBRATION OF A QUARTZ-CRYSTAL UNIT

Piezoelectric crystals were introduced into the radiofrequency field to meet the need for a resonant circuit (series or parallel) having constant parameters and high Q. A fundamental requirement was that the crystal unit be the electrical equivalent of a single resonant (or antiresonant) circuit. The unit that for practical purposes meets this requirement is called a normal one. Crystal units with interfering responses, or closely spaced multiple responses, are apparently equivalent to electrical circuit meshes with a number of mutually coupled resonant circuits. These are more complex units, and should be treated separately.

The equivalent circuit of a normal crystal unit is shown in Fig. 1(a). It has one resonant frequency f_r and one antiresonant frequency f_a for any particular value of shunting capacitance C_t . The impedance across its terminals R_p is illustrated by means of the susceptance with reactance diagrams of Fig. 1(c) and (d). R_s is small as compared with ωL , and can be neglected in these diagrams.

The susceptance B_{abc} of the L_1 , C_1 series branch is added to the susceptance B_t of the shunt capacitance C_t . C_t is the total shunt capacitance across the crystal plate, and is usually designated as C_0 when the capacitance external to the crystal unit is zero. The resultant

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 B_{\bullet} is obtained in Fig. 1(c) as the resultant termination reactance X_{\bullet} in Fig. 1(d). It is evident from the diagram that, as C_{i} is increased in value, the slope of B_{i} will increase, and f_{a} will approach f_{r} . It is also apparent that X_{\bullet} is positive between f_{r} and f_{a} . The equivalent circuit at frequencies in this range is, therefore, as shown in Fig. 1(b), where R_{\bullet} is the resistive component including the effect of the series resistance R_{\bullet} and all other losses of the unit.



Fig. 1—(a) Equivalent circuit of a quartz-crystal unit. (b) Effective impedance of a crystal unit between f_r and f_a . (c) Susceptance diagram of a crystal unit. (d) Reactance diagram of a crystal unit.

When such a circuit is tuned to antiresonance with an external capacitor, the termination impedance is resistive, and is equal to

$$R_p = Q_e X_e = \frac{X_e^2}{R_e}$$
 (1)

The termination impedance of the equivalent circuit of Fig. 1(b) (often referred to as the Performance Index, or PI) may also be expressed in terms of the shunt capacitance and the series resistance, as follows:

At any antiresonant frequency f_a (where $f_a > f_r$), the termination impedance is, for small values of R_s , equal to that of a tapped antiresonant circuit, and is resistive; namely,

$$Z_p = R_p = Z_x \frac{C_1^2}{(C_1 + C_t)^2}$$

where

$$Z_x = Q_x \frac{1}{\omega_a C_e} = \frac{1}{R_s(\omega_a C_e)^2}.$$

 Q_x is the Q of the antiresonant circuit, and

$$C_e = \frac{C_1 C_i}{C_1 + C_i} \cdot$$

Now,

$$R_{p} \doteq Z_{x} \frac{C_{s}^{2}}{C_{t}^{2}} = \frac{1}{R_{s}(\omega_{a}C_{t})^{2}} = \frac{X_{t}^{2}}{R_{s}} \cdot$$
(2)

And, from (1) and (2),

$$\frac{X_{\iota^2}}{R_{\bullet}} \doteq \frac{X_{\bullet^2}}{R_{\bullet}} \cdot \tag{3}$$

 R_p may be plotted versus C_t as an independent parameter on log-log co-ordinate paper in the form of a straight line with a negative 2-to-1 slope. This follows from (2), since

$$\log R_p = \log \left[\frac{1}{\omega^2 R_s C_t^2}\right] = \log \left[\frac{1}{\omega^2 R_s}\right] - 2 \log C_t.$$

 R_{\bullet} is assumed constant and the percentage change in ω with C_t negligible. Experimental evidence shown later supports these assumptions. Hence,

$$\log R_p = K_1 - 2 \log C_t. \tag{4}$$

Similarly, the antiresonant frequency increments $(f_a - f_r)$ may be plotted on log-log paper as a straightline function of C_t with a negative 1-to-1 slope. This may be shown as follows (see Fig. 1(a)):

$$\omega_r^2 = \frac{1}{L_1 C_1} \,. \tag{5}$$

The antiresonance frequency is determined from the interrelation:

$$\omega_a{}^2 = \frac{1}{L_1 \frac{C_1 C_t}{C_1 + C_t}} = \frac{C_1 + C_t}{L_1 C_1 C_t}$$

From this and (5),

$$\frac{\omega_a^2}{\omega_r^2} = \frac{f_a^2}{f_r^2} = \frac{(C_1 + C_t)C_1}{C_1C_t} = 1 + \frac{C_1}{C_t}$$

or

$$\frac{C_1}{C_t} = \frac{f_a^2}{f_r^2} - 1 = \frac{(f_a + f_r)(f_a - f_r)}{f_r^2} \cdot$$

For practical purposes, $f_a + f_r = 2f_r$. Hence,

$$(f_a - f_r) \doteq \frac{1}{2} \frac{f_r C_1}{C_t} \tag{6}$$

or

$$\log (f_a - f_r) \doteq \log \left(\frac{1}{2}f_r C_1\right) - \log C_t.$$

Since f_r and C_1 are constant,

$$\log (f_a - f_r) \doteq K_2 - \log C_t. \tag{7}$$

These straight-line characteristics ((4), (7)) of normal crystal units are demonstrated in Figs. 2, 3, and 4. Slopes of 2-to-1 and 1-to-1 were drawn for the straight-line sections in the figures. The position of each measured point shows how closely the theoretical curves are followed. Curvatures at high R_p values were caused by holder losses, as evidenced by the same characteristics measured, and plotted in Fig. 5, with the crystal removed from the holder.

It might seem at this time as if a single point on each of these R_p and $(f_a - f_r)$ versus C_t curves, through which the engineer could draw the appropriate 2-to-1 and 1-to-1 lines, would convey sufficient data for design purposes. And this could almost be done if the crystal unit in question were known to be normal, and if the



Fig. 2—Electrical characteristics of two 8.7-Mc wire-mounted crystal units with metal-film electrodes. These exhibit the 2-to-1 and 1-to-1 slopes derived from theory.



Fig. 3—Electrical characteristics of "normal" crystal units of different physical construction. (a) CR-1 type; air-gap, pressuremounted. (b) FT-243 type; metal-film, spring-clip mounting. (c) FT-243 type; air-gap, pressure-mounted.



Fig. 4—Electrical characteristics of two different 100-kc quartz crystal units; GT-cut, metal-film electrodes, wire-mounted crystal. Unit A had a low-loss holder.

engineer were supplied with such additional data as the values of C_0 and either f_r or f_a at C_0 . Still lacking, however, would be the effect of holder losses, and the frequency spectrum of the crystal unit showing the magnitude and disposition of secondary responses and data on parameter variation with temperature.



Fig. 5—Impedance measurements of the fundamental and adjacent responses on both sides of antiresonance of an air-gap, pressuremounted crystal unit. The effect of holder losses on the high R_p values of a crystal unit is shown. Fundamental response: (a) Lossy holder. (b) Low-loss holder. Secondary response: (c) Lossy holder. (d) Low-loss holder.

III. MEASUREMENT METHODS

Those parameters investigated in these measurements, which have not yet been defined and are not presented in Fig. 1, are:

 $\Delta C_t = \text{an increment of } C_t$

$$\Delta f = f_a - f_r$$

- R_h = resistance shunting the quartz crystal (equivalent to holder losses)
- $Q_e = X_e/R_e$ = the effective Q of the crystal unit
- $Q_x = (2\pi f L_1/R_s) = (1/2\pi f C_1 R_s)$ by definition, where f is the nominal frequency of the crystal unit. is usually referred to as the Q of the crystal.

Some useful expressions of parameters in terms of directly measurable quantities are derived as follows:

$$C_1 \doteq \frac{2\Delta f C_t}{f_r}$$
 = equation (6) rearranged. (8)

$$Q_x = \frac{1}{4\pi\Delta f C_t R_s} \text{from definition of } Q_x \text{ and } (8); \text{ noting that, } (9)$$

since $\Delta f \ll f_r$ any frequency between f_a and f_r can be used.

Measurements of f_a (to determine Δf) are usually made at $C_t = C_0$. Then,

$$Q_x = \frac{1}{4\pi\Delta f C_0 R_s} \tag{10}$$

$$L_1 = \frac{1}{(2\pi f_r)^2 C_1} \, \cdot \tag{11}$$

The effect of holder losses reduce R_p to

$$R_{p}' = \frac{R_{h}R_{p}}{R_{h} + R_{p}} \cdot \tag{12}$$

A. Q-Meter Measurements of Quartz-Crystal Unit Characteristics

The well-known Q-meter principle makes use of an antiresonant circuit arrangement as shown in the table (Fig. 6). For our purposes, constant rf voltage was applied directly to the 0.04-ohm resistance element in the Q-meter tank with the Q meter's internal oscillator disconnected by leaving the band switch in an intermediate position.

 L_Q , C_Q (Fig. 6) is tuned for antiresonance at the frequency at which X_e , R_e are to be measured. The crystal unit is connected in parallel with C_Q . Now the latter must be readjusted by ΔC_Q to restore the antiresonance at the Q-meter tank, and

$$X_e = \frac{1}{\omega \Delta C_Q} \,. \tag{13}$$

The voltage across the antiresonance tank is a measure of the Q of the circuit. Connecting the crystal unit in parallel with the tank reduces the original Q as a result of the shunt effect of R_{\bullet} . From the two values of Q,

$$R_{e} = \frac{1.59 \times 10^{8} \left(\frac{C_{Q_{1}}}{C_{Q_{2}}}Q_{1} - Q_{2}\right)}{fC_{Q_{1}}Q_{1}Q_{2}}$$
(14)

where C_{Q1} is the capacitance, in micromicrofarads, required to tune the Q-meter tank without the crystal unit, but at the crystal frequency; C_{Q2} is the capacitance, in micromicrofarads, required to tune the Q-meter tank with the crystal unit in parallel with it; Q_1 is the original Q of the tank; Q_2 is the reduced Q of the tank; and f is the nominal frequency of the crystal unit in kc.

PROCEEDINGS OF THE I.R.E.

PARAMETER	RANGE	INSTRUMENT	CIRCUIT ARRANGEMENT (FUNDAMENTAL SCHEMATIC)	PROCEDURE	PRECAUTIONS	ACCURACY, CONSERVATIVE ESTIMATE
STATIC	о то зо µµf			CALIBRATE Co	MEASURE CO AT I.T. FOR	±oiµµf
CAPACITY	30 TO 150 4141	"O" METER	ere f	VS. DIAL SETTING.	WHICH CRYSTAL IS INACTIVE	+ 02 µµf
AND	30 10 130 / 141		JEE 10	0.00 -0	POSITION AND SHIELDING	1 0.2 M/01
PARALLELING	150 TO 2000 µµf				OF CRYSTAL UNIT IS IMPORTANT	±sμμf
Δ C _t		TWIN-T		·····		
	100 TO 1100 µµf	IMPEDANCE - MEASURING CIRCUIT	SEE R _p	CALIBRATE CAPACITANCE DIAL		± 2 /u/uf
				ADJUST L _o C _o	USE SHORTED TERMINALS	
SERIES-	"Q" METER	"O" METER		FOR MAXIMUM V.	OR SMALLEST LOOP	± 1.5 IN 10 ⁶
RESONANCE				ADJUST r.f.	FOR INDUCTIVE COUPLING	
FREQUENCY,				FOR MINIMUM V.	TO GRESTAL UNIT	
f,					· · · ·	
	R-F BRIDGE	R-F BRIDGE	SEE R AND R (HIGH LEVEL)	ADJUST r. f., AND RESISTANCE ARM	SHIELD WELL. NO F.M.	± 1.5 IN 10 ⁶
				OF BRIDGE FOR BALANCE	IN OUTPUT OF P-T GENERATOR	
				UNE "Q" METER TO T. PLACE CRYSTAL	FOR MAXIMUM PRECISION	
ANTIRESONANCE	"Q" METER	"Q" METER		r.f. FOR MAX. V. REMOVE CRYSTAL UNIT		± 2.5 IN 10 ⁶
FREQUENCY.				AND RETURE "Q" METER. REPLACE	USE LARGE 1/2 RATIO	
			ت ت	FOR MAX V.	, IN "Q" METER	
t _o			~			
			· · · · · · · · · · · · · · · · · · ·	ADJUST r. f., AND C. ARM		
	TWIN-T CIRCUIT	TWIN-T CIRCUIT	SEE R _p (LOW LEVEL)	OF BRIDGE FOR BALANCE	SHIELD WELL	± 2.5 IN 10"
SERIES RESISTANCE	о то 1000 онмз				SHIELD WELL. USE LOW	± 0.2 OHMS ± 2%
Re; AND	O TO 500 OHMS(AT IO Mc.)	R-F BRIDGE	SEE R _s	ROUTINE	r-f INPUT TO BRIDGE	± I OHM ± 1%
	5000 TO 10,000 OHMS					± 5% OR BETTER
				SUBSTITUTION METHOD ADJUST r f	FOR MAXIMUM PRECISION	
	10,000 TO 100,000 OHMS	"Q" METER	SEE fa		ADJUST C. FOR MAX V	± 2%
	10,000 TO 100,000 OHMS	"Q" METER	SEE fa	FOR MAXIMUM V. AT EACH & C	ADJUST Co FOR MAX.V.	± 2% ± 5% OR BETTER
ANTIRESONANCE	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS	"Q" METER		FOR MAXIMUM V. AT EACH ΔC_t	ADJUST Co FOR MAX.V.	± 2% ± 5% OR BETTER
	10,000 TO 100,000 OHMS	"Q" METER		FOR MAXIMUM V. AT EACH & C	ADJUST CO FOR MAX.V.	± 2%
ANTIRESONANCE	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 10000 TO 18,000 OHMS	"Q" METER TWIN T CIRCUIT		FOR MAXIMUM V. AT EACH & C	ADJUST CO FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE	± 2% ± 5% OR BETTER ± 2.5%
ANTIRESONANCE IMPEDANCE, Rp	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS	"Q" METER TWIN-T CIRCUIT			ADJUST CO FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE	± 2% ± 5% OR BETTER ± 2.5%
ANTIRESONANCE IMPEDANCE, R _p	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS	"Q" METER TWIN T CIRCUIT			ADJUST CO FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL	± 2% ± 5% OR BETTER ± 2.5%
ANTIRESONANCE IMPEDANCE, R _P (LOW LEVEL)	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS	"Q" METER TWIN T CIRCUIT	SEE fo	FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH	ADJUST C _Q FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT	± 2% ± 5% OR BETTER ± 2.5 % ± 0.1 OHMS
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL)	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE		FOR MAXIMUM V. AT EACH & C _L ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH GALIBRATED SILVER-MICA CONDENSERS	ADJUST Co FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO F.M. IN	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 15%
ANTIRESONANCE IMPEDANCE, R _p (LOW LEVEL)	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE	SEE fa	ADJUST I. I., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT	ADJUST CO FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO F.M. IN OUTPUT OF r-f GENERATOR	± 2% ± 5% OR BETTER ± 2.5 % ± 0.1 OHMS ± 1.5 %
ANTIRESONANCE IMPEDANCE, R _p (LOW LEVEL)	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE	SEE fo	FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT	ADJUST CO FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR	± 2% ± 5% OR BETTER ± 2.5 % ± 0.1 OHMS ± 15 %
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL)	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 10000 TO 18,000 OHMS 0 TO 1000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL	SEE fo	FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD	ADJUST C _Q FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT	± 2% ± 5% OR BETTER ± 2.5 % ± 0.1 OHMS ± 15 %
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (HIGH LEVEL)	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL	SEE fo	FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD	ADJUST CO FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO F.M. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 1.5% ± 5%
ANTIRESONANCE IMPEDANCE, R _p (LOW LEVEL) R _p (HIGH LEVEL)	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 100.0 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER	SEE f _a	FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT	ADJUST Co FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO F.M. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM	± 2% ± 5% OR BETTER ± 2.5 % ± 0.1 OHMS ± 1.5 % ± 5 %
ANTIRESONANCE IMPEDANCE, R _P (LOW LEVEL) R _P (HIGH LEVEL)	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE	SEE f ₀ SEE f ₀	FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE fr	ADJUST C _Q FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 15% ± 5% ± 5%
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (HIGH LEVEL) SERIES-	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS 1000 TO 100,000 OHMS 0 TO 1000 OHMS 1000 TO 10,000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE	SEE f ₀	FOR MAXIMUM V. AT EACH & CL FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE fr SUBSTITUTION METHOD	ADJUST C _Q FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr	
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (HIGH LEVEL) SERIES- RESONANCE	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS 1000 TO 100,000 OHMS 1000 TO 10,000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE	SEE f ₀	FOR MAXIMUM V. AT EACH & CL FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE fr SUBSTITUTION METHOD	ADJUST CQ FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO F.M. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD LQ COILS	
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (MIGH LEVEL) SERIES- RESONANCE RESISTANCE,	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS 0 TO 1000 OHMS 0 TO 1000 OHMS 1000 TO 10,000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE	SEE f ₀	FOR MAXIMUM V. AT EACH \triangle C _L ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE f, SUBSTITUTION METHOD	ADJUST Co FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO F.M. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD Lo COILS AND LOW LOC ATIOS	
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (MIGH LEVEL) SERIES- RESONANCE RESISTANCE, Rs	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS 1000 TO 100,000 OHMS 0 TO 1000 OHMS 1000 TO 10,000 OHMS 0 TO 10 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE	SEE f ₀	FOR MAXIMUM V. AT EACH & CL FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE fr SUBSTITUTION METHOD SUBSTITUTION METHOD	ADJUST CO FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD LO COILS AND LOW LOCORS	$\pm 2\%$ $\pm 5\% \text{ OR BETTER}$ $\pm 2.5\%$ $\pm 0.1 \text{ OHMS}$ $\pm 15\%$ $\pm 5\%$ $\pm 5\%$ $\pm 5\%$ $\pm 25\%$
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (HIGH LEVEL) SERIES- RESONANCE RESISTANCE, Rs	10,000 TO 100,000 OHMS 100,000 TO 5,000,000 OHMS 1000 TO 18,000 OHMS 0 TO 1000 OHMS 0 TO 100,000 OHMS 0 TO 10000 OHMS 1000 TO 10,000 OHMS	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE "Q" METER	SEE f_0	FOR MAXIMUM V. AT EACH & CL FOR MAXIMUM V. AT EACH & CL ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE f, SUBSTITUTION METHOD SUBSTITUTION METHOD ADJUST LC FOR MAXIMUM I,	ADJUST CO FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD LO COILS AND LOW LOCOLS	
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (HIGH LEVEL) SERIES- RESONANCE RESISTANCE, Rs AND	10,000 то 100,000 онмs 100,000 то 5,000,000 онмs 1000 то 18,000 онмs 0 то 1000 онмs 0 то 100,000 онмs 1000 то 10,000 онмs 1000 то 10,000 онмs 0 то 10 онмs	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE "Q" METER SPECIAL	SEE f_0	FOR MAXIMUM V. AT EACH \triangle C ₁ FOR MAXIMUM V. AT EACH \triangle C ₁ ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE f_r SUBSTITUTION METHOD SUBSTITUTION METHOD ADJUST L,C FOR MAXIMUM I, AND E _p FOR DESIRED I VALUE	ADJUST CQ FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD LQ COILS AND LOW LQ/CQ RATIOS CALIBRATE I AND V	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 15% ± 5% ± 5% ± 2.5% NOT FULLY
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (HIGH LEVEL) SERIES- RESONANCE RESISTANCE, Rs AND fr	10,000 то 100,000 онмs 100,000 то 5,000,000 онмs 1000 то 18,000 онмs 0 то 1000 онмs 0 то 1000 онмs 1000 то 10,000 онмs 1000 то 10,000 онмs 0 то 10 онмs	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE "Q" METER SPECIAL CIRCUIT	SEE f_0	FOR MAXIMUM V. AT EACH \triangle C _L ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE f, SUBSTITUTION METHOD SUBSTITUTION METHOD ADJUST L,C FOR MAXIMUM I, AND E _p FOR DESIRED I VALUE ADJUST C, FOR MINIMUM V.	ADJUST CQ FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO F.M. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD LQ COILS AND LOW LQ/CQ RATIOS CALIBRATE I AND V	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 1.5% ± 5% ± 5% ± 2.5% NOT FULLY INVESTIGATED
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (HIGH LEVEL) SERIES- RESONANCE RESISTANCE, Rs AND f, (HIGH LEVEL)	10,000 то 100,000 ония 100,000 то 5,000,000 ония 1000 то 18,000 ония 0 то 1000 ония 0 то 1000 ония 0 то 1000 ония 0 то 10,000 ония 0 то 10 ония 0 то 10 ония 0 то 10 ония 0 то 10 ония	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE "Q" METER SPECIAL CIRCUIT ARRANGEMENT	SEE f ₀	FOR MAXIMUM V. AT EACH $\triangle C_L$ ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE f, SUBSTITUTION METHOD SUBSTITUTION METHOD ADJUST LC FOR MAXIMUM I, AND E _p FOR DESIRED I VALUE ADJUST C ₁ FOR MINIMUM V. R ₉ = $\frac{V}{T}$	ADJUST CQ FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD LQ COILS AND LOW LQ/CQ RATIOS CALIBRATE I AND V SEE Rp (HIGH LEVEL)	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 1.5% ± 5% ± 5% ± 5% ± 2.5% NOT FULLY INVESTIGATED
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) RP (HIGH LEVEL) SERIES- RESISTANCE, Rs AND f, (HIGH LEVEL)	10,000 то 100,000 онмs 100,000 то 5,000,000 онмs 1000 то 18,000 онмs 0 то 1000 онмs 0 то 1000 онмs 1000 то 10,000 онмs 1000 то 10,000 онмs 0 то 10 онмs 0 то 10 онмs 0 то 100 онмs АND ABOVE	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER R-F BRIDGE "Q" METER SPECIAL CIRCUIT ARRANGEMENT	SEE f_0	FOR MAXIMUM V. AT EACH $\triangle C_{L}$ FOR MAXIMUM V. AT EACH $\triangle C_{L}$ ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SEE f, SUBSTITUTION METHOD SUBSTITUTION METHOD ADJUST L,C FOR MAXIMUM I, AND E _p FOR DESIRED I VALUE ADJUST C ₁ FOR MINIMUM V. R ₈ = $\frac{V}{L}$	ADJUST CQ FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD LQ COILS AND LOW LQCQ RATIOS CALIBRATE I AND V SEE Rp (HIGH LEVEL)	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 15% ± 5% ± 5% ± 5% ± 2 5% NOT FULLY INVESTIGATED
ANTIRESONANCE IMPEDANCE, R _p (LOW LEVEL) R (HIGH LEVEL) SERIES- RESONANCE RESISTANCE, R ₈ AND f ₇ (HIGH LEVEL)	10,000 то 100,000 онмs 100,000 то 5,000,000 онмs 10000 то 18,000 онмs 0 то 100 0 онмs 0 то 100,000 онмs 0 то 100,000 онмs 1000 то 10,000 онмs 0 то 10 онмs 0 то 10 онмs 0 то 100 онмs AND ABOVE	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER SPECIAL CIRCUIT ARRANGEMENT "Q" METER	SEE f_0 SEE f_0	FOR MAXIMUM V. AT EACH $\triangle C_1$ FOR MAXIMUM V. AT EACH $\triangle C_1$ ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SUBSTITUTION METHOD SUBSTITUTION METHOD SUBSTITUTION METHOD ADJUST L.C. FOR MAXIMUM I, AND E _p FOR DESIRED I VALUE ADJUST C ₁ FOR MAXIMUM V. R ₈ = $\frac{V}{T}$ ADJUST r.f. FOR MAXIMUM V. AT A VALUE HIGHER THAN f.	ADJUST CQ FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE fr USE GOOD LQ COILS AND LOW LQCQ RATIOS CALIBRATE I AND V SEE Rp (HIGH LEVEL) V IS MAXIMUM WHEN CQ CQ AND	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 15% ± 5% ± 5% ± 5% ± 2.5% NOT FULLY INVESTIGATED NOT FULLY
ANTIRESONANCE IMPEDANCE, Rp (LOW LEVEL) Rp (HIGH LEVEL) SERIES- RESONANCE RESISTANCE, Rs AND fr (HIGH LEVEL) Rp	10,000 то 100,000 онмs 100,000 то 5,000,000 онмs 1000 то 18,000 онмs 0 то 100 0 онмs 0 то 100,000 онмs 0 то 100,000 онмs 1000 то 10,000 онмs 0 то 10 онмs 0 то 10 онмs AND ABOVE 5,000 то 5,000,000 онмs	"Q" METER TWIN-T CIRCUIT R-F BRIDGE SPECIAL HIGH LEVEL "Q" METER SPECIAL CIRCUIT ARRANGEMENT "Q" METER WITH LOW CA	SEE f_0	FOR MAXIMUM V. AT EACH $\triangle C_1$ FOR MAXIMUM V. AT EACH $\triangle C_1$ ROUTINE ADJUST r.f., AND RESISTANCE ARM OF BRIDGE FOR BALANCE WITH CALIBRATED SILVER-MICA CONDENSERS IN PARALLEL WITH CRYSTAL UNIT SUBSTITUTION METHOD USE I TO 5 WATT r-f INPUT SUBSTITUTION METHOD SUBSTITUTION METHOD ADJUST L,C FOR MAXIMUM I, AND E _p FOR DESIRED I VALUE ADJUST C ₁ FOR MAXIMUM V. R _s = $\frac{V}{I}$ ADJUST r.f. FOR MAXIMUM V. AT A VALUE HIGHER THAN f,	ADJUST C_{Q} FOR MAX.V. SHIELD WELL USE LOW r-f INPUT TO BRIDGE SHIELD WELL USE LOW r-f INPUT TO BRIDGE. NO FM. IN OUTPUT OF r-f GENERATOR PERMIT CRYSTAL UNIT TO REACH TEMPERATURE EQUILIBRIUM SEE f_r USE GOOD L _Q COILS AND LOW L_{QC_Q} RATIOS CALIBRATE I ANDV SEE R_p (HIGH LEVEL) V IS MAXIMUM WHEN $C_Q \cdot C_Q$ AND EDECIUENCY of Δf	± 2% ± 5% OR BETTER ± 2.5% ± 0.1 OHMS ± 15% ± 5% ± 5% ± 5% ± 2.5% NOT FULLY INVESTIGATED NOT FULLY INVESTIGATED

Fig. 6-Tabulation of measurement methods and the accuracies attained.

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The values of R_p and R_s may also be derived directly in terms of the Q's observed:

$$R_{p} = \frac{1.59 \times 10^{8} Q_{1}Q_{2}}{fC_{Q_{1}}(Q_{1} - Q_{2})}$$
(15)

$$R_{s} = R_{p'} \left[\frac{(Q_{1} - Q_{2})C_{Q_{1}}}{Q_{1}Q_{2}(C_{Q_{2}} - C_{Q_{1}})} \right]^{2}$$
(16)

where the symbols are as stated above.⁶

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 R_p measurements from values of 5 million down to several thousand ohms were readily made with the Q meter using the above formulas. It was found, however, that a direct substitution of calibrated rf resistors in place of the crystal unit (across the Q-meter tank) eliminated time-consuming computations, with no sacrifice in accuracy.

Each of a number of coils was resonated at the desired frequency and its Q_2 values (see (14)) plotted on semilog paper against rf resistors (on the logarithmic co-ordinate) causing the drop in Q. Measurements of R_p at any frequency within a given crystal-unit response were made. At the fixed frequency, the Q-meter tank (with crystal unit in shunt) was resonated by tuning the capacitor C_Q to a maximum Q_2 indication. Measured Q_2 values were converted directly into corresponding R_p values from the resistance (R_p) versus Q_2 calibration curves. The over-all accuracy (conservatively estimated and tabulated in Fig. 6) is limited by the accuracy to which the rf values of the resistors used for calibration are known, and by the reproducibility of Q-meter readings. The inductance and the Q of a specific tuning coil determine the resistance range for greatest accuracy.

To measure the series-resonance frequency, an unshielded coil was resonated in the Q meter at a frequency near that of the crystal unit. The crystal unit was shortcircuited and placed near the low-voltage end of the coil. The Q-meter frequency was varied until a sharp dip indicated the f_r of the crystal unit.

Measurements of f_a , when $C_t = C_0$, were made with the crystal unit in parallel with the Q-meter coil. The coil was first resonated at the nominal frequency of the unit. After the insertion of the crystal, the frequency was varied until the Q indicator rose to a maximum. With the crystal unit again removed, the coil was resonated at constant frequency by adjusting C_Q . Again the crystal unit was placed in the circuit and the frequency adjusted to a maximum Q indication. These adjustments were repeated until a constant frequency value (f_a) was obtained. At this point $C_t = C_0$. For highest precision a final adjustment of C_Q to a maximum Q indication was made at constant frequency. It will be recognized that the Q indication (Q_2) yielded the impedance R_p of the crystal unit for this operating point, as previously described.

• At high R_p values, $R_{p'}$ (equation 12) must be used to correct for holder losses.

To measure f_a , when $C_t \neq C_0$, the Q-meter capacitance was changed from the $C_t = C_0$ setting by the ΔC required to bring the operating point to the desired frequency within the crystal response, and the frequency was varied to the new f_a indicated by the peaking of the Q indicator. Again the Q_2 value yielded the R_p of the crystal unit for this new operating point between f_a and f_r .

The Q meter was used for measurements of R_s directly. The crystal units were connected in series with the tank coil for low R_s values (up to 10 ohms), and in parallel with the tank for values higher than 1000 ohms. An rf impedance bridge was found to be more suitable for measurements of R_s from 1 to 1000 ohms.

Values of R_p at crystal-unit voltages approaching those in a Miller- (or Pierce-) type oscillator were measured with a Q-meter circuit specifically constructed for the purpose (Fig. 6; see R_p high level). Stable frequency voltage was injected into the LC tank by link-coupling the output of an auxiliary amplifier into a small section of the tank inductance. Sensitive thermoelements and potentiometers were used for current and O indicators. Care was taken in the measurements to avoid frequency-response shift as the temperature of the crystal varied with the current through it. The technique was modified to permit presetting the voltage levels desired. Since there was no apparent difference in R_p values at high and low voltages (Fig. 7), there seems to be little need for high-voltage measurements, and the procedure is not elaborated upon.



Fig. 7—Correlation between R_p values measured at high and at low rf voltages across the crystal units. Five units were measured with four different values of shunting capacitance.

It should be observed that, when a crystal unit is connected in parallel with an antiresonant circuit tuned approximately to the crystal frequency, there are present two antiresonance peaks of the circuit impedances.⁴ The lower peak is not influenced by the frequency response of the crystal unit, and appears at a separation many times the width of f_a-f_r . Hence, it does not affect the measurements.

The Q meter was singularly useful in locating and measuring secondary responses. The Q-meter tank was tuned to a frequency just below the nominal frequency of the crystal unit. The frequency was then increased continuously, with the crystal unit in parallel with the tank. Voltage dips were observed at f_r points, and peaks at f_a points in the frequency spectrum. Individual responses were closely explored by returning the tank (crystal unit removed) and repeating the sweep of frequency (crystal unit replaced) to determine more exactly the values of f_r and f_a . The process of returning the tank and of readjusting the frequency was repeated to a final unchanging frequency.

Tank coils of high inductance were effective in locating f_a points, while low-inductance tank coils were more effective in locating f_r 's. For most precise measurements, different coils were used as conditions warranted.

It was found enlightening to plot the relative position of the secondary responses on semilog paper as shown in Fig. 8. For practical purposes, it might be sufficient to interconnect the R_s and R_p points of each response



Fig. 8—Frequency-response spectrum of a metal-film-electrode, wiremounted crystal unit. The curves connect measured R_p and R_s values for each response. The single points represent R_p values of responses whose R_s values are uncertain.

with a straight line, for the curvature involved is negligible relative to the frequency scale employed. This approximation may be justified analytically when considering the variation of R_e within a single response, between f_r and f_a .

Designating the total series reactance of the equivalent circuit of Fig. 1(a) as

$$X_1 = \omega L_1 - \frac{1}{\omega C_1}$$
, and $X_0 = \frac{1}{\omega C_0}$

the termination impedance of the unit is

$$Z = X_0 \frac{X_0 R_s + j [R_s^2 + X_1 (X_1 + X_0)]}{R_s^2 + (X_1 + X_0)^2}$$

Then

$$|Z| = X_0 \frac{\{X_0^2 R_s^2 + [R_s^2 + X_1(X_1 + X_0)]^2\}^{1/2}}{R_s^2 + (X_1 + X_0)^2}$$

The equivalent series values of R_e and X_e are then

$$R_{e} = \frac{X_{0}^{2}R_{s}}{R_{s}^{2} + (X_{1} + X_{0})^{2}},$$
(17)

and

$$X_{e} = \frac{X_{0} [R_{s}^{2} + X_{1}(X_{1} + X_{0})]}{R_{s}^{2} + (X_{1} + X_{0})^{2}} \cdot$$
(18)

For practical purposes, at f_a the reactive component of Z vanishes, and $X_1+X_0=0$; therefore,

$$Z_{a} \doteq R_{p} \doteq \frac{X_{0}^{2}R_{s}}{R_{s}^{2}} = \frac{X_{0}^{2}}{R_{s}} \doteq R_{e}'$$
(19)

where R_{e}' is the value of R_{e} at f_{a} .

At f_r , X_1 is zero, and

$$|Z| = X_0 \frac{[X_0^2 R_s^2 + R_s^4]^{1/2}}{R_s^2 + X_0^2} = \frac{X_0 R_s}{(X_0^2 + R_s^2)^{1/2}}$$

For values $X_0 \gg R_s$, $Z \doteq R_s$. Similarly, at f_r , X_1 is zero, and, from (17),

$$R_{e} = \frac{X_{0}^{2} R_{s}}{R_{s}^{2} + X_{0}^{2}} \doteq R_{s}.$$
 (20)

It is apparent, therefore, that for responses having series-resistance values considerably lower than X_0 , plotting R_s versus frequency (Fig. 8) would closely represent a quantitative variation of the parameter of the crystal unit within the limits of R_s and R_p . For responses with high series-resistance values, this presentation of a response is correct at the R_p and R_s points only. In the curves shown, the R_p and R_s values representing the top and bottom points of each response are the measured values of these parameters; the intermediate points have qualitative significance only.

The Q meter was used to locate the responses. The R_p and R_s values were then measured with Q meter, twin tee, or rf bridges, depending on the magnitude of the parameter. Some of the relatively small secondary responses (R_s values above 1000 ohms) behaved in a

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manner that made the measurement of R_p uncertain. Further study of this behavior will be required, and these responses are here represented by a single point of measured R_s . Other responses at, and below, the threshold of detectability with the Q meter have been neglected as insignificant in this study.

B. Twin-Tee Circuit and Impedance Bridge

A twin-tee admittance-measuring circuit was used for R_p values of 1000 to 10,000 ohms. Resistance values computed from the admittances obtained were checked often against measurements of rf resistors maintained as standards. Increments of C_t applied across the crystal units (either by varying the internal capacitor of the instrument or by connecting external capacitors across them) were known to high accuracy at the operating frequencies.

It is possible to measure X_e and R_e of a crystal unit directly with the twin tee. However, the relatively limited range of measurable X_e at corresponding R_e values renders the instrument useful only for checking a few points obtained with the Q meter. Its use, therefore, yields little additional information.

An rf impedance bridge was used to measure R_s , R_e and X_s values from 1000 down to a few ohms, and R_e values down to 100 ohms. In fact, R_p values as low as 10 ohms were actually measured with 8.7-Mc crystal units. However, the validity of the latter was uncertain.

In measuring R_s and R_p with the bridge, the frequency and resistance arms were varied until a minimum deflection on the null balance indicator was obtained. R_s was measured more rapidly by first determining f_r with the Q meter, as described above. R_p values when $C_t \neq C_0$ were measured with external capacitors connected in shunt with the crystal-unit terminals. R_e and X_e values were obtained at any frequency by adjusting the resistance and reactance arms for a null balance. The major requirement in the application of the twin tee and rf bridge was a source of stable frequency, adjustable in small increments. Good wave form without frequency modulation was found essential for a sharp null balance.

The equipment shown in the block diagram of Fig. 9 was used for 8.7-Mc crystal-unit measurements. A standard frequency of 100 kc was injected into a frequency multiplier, the products of which were mixed with the output of a continuously adjustable stable-frequency oscillator. The output of the mixer was then amplified to the desired level.

Frequency could be adjusted, measured, and maintained to better than 5 parts in 10⁷ over a period of time required to complete any one measurement. Regular frequency-measuring equipment incorporating a radio receiver as a detector, a stable audio-frequency oscillator to determine the beat frequency between the adjustable oscillator and a harmonic of the standard source, and an oscillograph were used throughout the measurements. A second radio receiver was used as a null indicator for the twin tee and rf bridge.

Special circuits were developed and used to measure independently and directly the values of the series-resonant resistance R_s and series-resonant frequency f_r . Fig. 6 lists the methods, accuracies, and range of parameters measured.

IV. A COMPLEX CRYSTAL UNIT

A great difficulty encountered in this investigation was that of locating and segregating a group of quartzcrystal units whose characteristics could be measured, and the results reproduced to an accuracy near that of the measuring equipment. Stability tests of R_s , of R_p , and of "activity" were made over a period of weeks, and only the most highly stable units were used for measurement.



Fig. 9-Block diagram of the apparatus used.

Among those in the select group, there were a few relatively stable with respect to R_s and to "activity," but with R_p (and Δf) versus C_t characteristics which deviated considerably in slope from the expected 2-to-1 and 1-to-1 ratios. A typical example is shown in Fig. 10.



Fig. 10—Electrical characteristics of two interfering responses of a "complex" crystal unit. (a) f_r : 8697.87 kc. (b) f_r : 8700.40 kc.



Fig. 11-Frequency-response spectrum of a "complex" crystal unit. The large number of responses should be compared with the rela-tively few in Fig. 8. The position and magnitude of the antiresonant impedances of the first two responses are indicative of the behavior shown in Fig. 10, and described in the text.

At C_i values between C_0 and 75 $\mu\mu f$, the first response (A) has higher R_p 's than the second; and the crystal should operate at the frequency of the former. Above 75 $\mu\mu$ f, the R_p values of the second response are higher; and here the crystal should operate on the second response. This frequency jump from one response to the next was observed in a Miller-type oscillator at the stated C_t value.

It is probable that the presence of many an interfering response will not show up in test oscillators in use at present. This particular one was detected in other measurements: abnormally high R_s , and an unusually wide Δf . The frequency spectrum of this particular crystal unit is shown in Fig. 11. It demonstrates the proximity and the relative values of R_p , R_s , and Δf of all responses; and this frequency spectrum should be compared with the spectrum of the normal crystal unit as shown in Fig. 8.

The role of the second response as an interfering one was again indicated by a decrease in R_e as the frequency was increased from f_r . From the minimum, reached several hundred cycles above series resonance, R_e then increased in a more normal manner. This is not intended to indicate a specific manner of behavior of a complex crystal-unit response, but to point out another practical means of exploring such behavior. Further study of this type of crystal should be undertaken as a separate problem, employing methods of measurement described here.

V. CORRELATION BETWEEN MEASURED CHARACTER-ISTICS AND OSCILLATOR PERFORMANCE OF CRYSTAL UNITS

It has been shown in a number of publications^{5,7,8} that the activity of a crystal in an oscillator is a function of the equivalent dynamic resistance R_p (PI) of the crystal unit. The higher the Q of a crystal unit, the greater its stability and effectiveness in electric circuits. The relative merits of crystal units may be stated, then, in terms of these parameters.

To verify this, activity, (I_g) , and R_p measurements were performed on a number of crystal units of varying degrees of stability. Fig. 12 shows thirteen such units with three values of C_t and their corresponding R_p 's measured at voltages approximating those across the crystal unit in a Miller-type oscillator. R_p was measured immediately after an I_{g} measurement to prevent any change in characteristics as a result of handling. To further minimize differences, the activity was later reduced by lowering the oscillator plate voltage, while the R_p measurements were made at the low-voltage levels of the Q meter. These results agree with those in Fig. 12. There is a good correlation between high- and low-activity crystals and their respective R_p values. Moreover, there is good correlation between variation

⁷ I. E. Fair, "Piezoelectric crystals in oscillator circuits," Bell Sys. Tech. Jour., vol. 24, pp. 161-216; April, 1945.
⁸ M. Boella, "Performance of piezo-oscillators and the influence of the decrement of quartz on the frequency oscillations," PROC. I.R.E., vol. 19, pp. 1252-1274; July, 1931.

in activity of individual crystals and corresponding variation in their R_p values.

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Still another correlation exists between the R_s of a crystal unit and its activity in a Miller-type oscillator at various temperatures. Variations in R_s were measured with the crystal unit under test placed in a temperature-controlled cabinet and connected to the impedance bridge through a half-wavelength coaxial cable. Corrections were made for losses in the cable. No difficulties were encountered in the application of the coaxial cable to these measurements.

Another graphical presentation of the effect of temperature on the quartz-crystal unit is shown in Fig. 13. In curve A, a relatively high crystal current resulted in a resonance-frequency turning point at an ambient temperature of 3°C. Actually, the high crystal current brought the enclosed crystal plate to a temperature of about 44°C (the nominal turning point), even though the ambient indicating thermometer read 3°C. Curve B shows the resultant shift in turning point to an ambient of 15°C as the crystal assembly was removed from its enclosure and exposed to free ventilation. In curve C,



Fig. 12—Correlation between R_p and activity (grid current I_p) of thirteen pressure-mounted crystal units.

Since I_x activity is a function of R_p , it is also a function of R_s and of C_t (2). Observations were made, therefore, on the effect of temperature on C_0 . As expected, no detectable variations were found. It may be assumed, then, that the activity variations were caused entirely by changes in R_s .

VI. Additional Observations in Crystal-Unit Measurements

Temperature effects on the relative position of crystalunit responses and their R_p , R_s , and $f_a - f_r$ values were measured by the methods described. This type of measurement may be of value in the study of activity dips.



Fig. 13—Effect of operating conditions on the temperature and frequency turning point at resonance of an 8.7-Mc crystal; *BT*-cut, metal-film electrodes, wire-mounted. (A) Crystal in plastic holder, measured with relatively high crystal current. (B) Conditions same as (A), but crystal removed from holder. (C) Crystal in holder again, measured at negligible crystal current.

the crystal current was made negligible, and a full 44°C ambient temperature was necessary to bring the crystal plate to its frequency turning point.

Thus any predetermination of frequency turning point with temperature by a manufacturer or a design engineer must take into consideration at least the approximate amplitude of oscillation expected of the crystal unit and the mechanical design of the crystalplate holder and electrodes, insofar as heat dissipation is concerned. This is in keeping with the observation that the graphical curves suggested for use in design work should be accomplished by temperature data for a more complete expression of the characteristics of a quartz-crystal unit.

VII. CONCLUSION

It was shown that comprehensive data on electrical characteristics of quartz-crystal units may be obtained with rf bridges and Q meters and a source of constant cw frequency. Electrical characteristics of fundamental or of secondary responses may be measured equally well by the methods described.

Graphical presentation of measured parameters as straight-line functions on log-log co-ordinate paper was suggested as particularly suitable for design purposes. Examples of crystal behavior were given to demonstrate this presentation.